



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1092**
Hiroto YUKAWA et al. : Attorney Docket No. 2004_0499
Serial No. 10/810,902 : Group Art Unit 1752
Filed March 29, 2004 : Examiner Sin J. Lee

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION : **Mail Stop: Amendment**

RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action dated March 27, 2006.